Masachika Toguchi

List of Publications by Year in descending order

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1478505 1588992 9 95 6 8 citations h-index g-index papers 9 9 9 72 docs citations times ranked citing authors all docs

#	Article	IF	CITATIONS
1	Effects of a photo-assisted electrochemical etching process removing dry-etching damage in GaN. Japanese Journal of Applied Physics, 2018, 57, 121001.	1.5	25
2	Simple wet-etching technology for GaN using an electrodeless photo-assisted electrochemical reaction with a luminous array film as the UV source. Applied Physics Express, 2019, 12, 031003.	2.4	21
3	Electrodeless photo-assisted electrochemical etching of GaN using a H3PO4-based solution containing S2O8 2– ions. Applied Physics Express, 2019, 12, 066504.	2.4	14
4	Self-termination of contactless photo-electrochemical (PEC) etching on aluminum gallium nitride heterostructures. Applied Physics Express, 2020, 13, 026508.	2.4	13
5	Low-Damage Etching for AlGaN/GaN HEMTs Using Photo-Electrochemical Reactions. IEEE Transactions on Semiconductor Manufacturing, 2019, 32, 483-488.	1.7	6
6	Photoelectrochemical Etching Technology for Gallium Nitride Power and RF Devices. IEEE Transactions on Semiconductor Manufacturing, 2019, 32, 489-495.	1.7	6
7	Thermal-assisted contactless photoelectrochemical etching for GaN. Applied Physics Express, 2020, 13, 046501.	2.4	6
8	Self-terminating contactless photo-electrochemical (CL-PEC) etching for fabricating highly uniform recessed-gate AlGaN/GaN high-electron-mobility transistors (HEMTs). Journal of Applied Physics, 2021, 130, .	2.5	4
9	Fabrication of porous gallium nitride (GaN) utilizing two-step etching method and control of its optical properties. Denki Kagaku, 2021, 89, 365-369.	0.0	0